Notice of References Cited

Application/Control No. 10/566,686	Applicant(s)/Pater Reexamination LIU ET AL.	nt Under
Examiner	Art Unit	
JONATHAN C. LANGMAN	1784	Page 1 of 2

U.S. PATENT DOCUMENTS

				Old Title To To The Title Titl	
*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	Α	US-5,633,194	05-1997	Selvakumar et al.	117/103
	В	US-			
	С	US-			
	D	US-			
	Е	US-			
	F	US-			
	G	US-		-	
	Н	US-			
	Т	US-			
	J	US-			
	к	US-			
	L	US-			
	М	US-			

FOREIGN PATENT DOCUMENTS

	FOREIGN FATENT DOCUMENTS					
*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	0					
	Р					
	Q					
	R					
	s					
	т					

NON-PATENT DOCUMENTS

*					
Ľ		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)			
	U	Kanel et al., "Ballistic-Electron-Emission spectroscopy", Applied Phsylcs A, Vol. 72, (2001), pgs S227-S232.			
	v	Meyer et al., "Electron and hole Focusing in CoSi2/Si(111) Observed by ballistic Electron emission Microscopy", Physical Review Letters, Col. 85, 2000, pgs 1520-1523.			
	w	Seto et al., "Si/SiGe resonant cavity photodiodes for optical storage applications", Applied Physics Letters, Vol. 72, 1998, pg 1550-1552.			
	x	Kubler et al., "Si adatom surface migration biasing by elastic strain gradients during capping of Ge or Si1-xGex hut islands", Applied Physics letters, Col. 73, 1998, pgs 1053-1055.			

A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)

Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.

Notice of References Cited

Application/Control No. 10/566,686	Applicant(s)/Pater Reexamination LIU ET AL.	nt Under
Examiner	Art Unit	
JONATHAN C. LANGMAN	1784	Page 2 of 2

II S PATENT DOCUMENTS

				U.S. PATENT DOCUMENTS	
*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	Α	US-			
	В	US-			
	С	US-			
	D	US-			
	Е	US-			
	F	US-			
	G	US-		-	
	Н	US-			
	T	US-		_	
	J	US-			
	к	US-			
	L	US-			
	м	US-			

FOREIGN PATENT DOCUMENTS

	FOREIGN FATERT DOCUMENTS					
*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	0					
	Р					
	Q					
	R					
	s					
	Т					

NON PATENT DOCUMENTS

*	-	Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Sutter et al., "Embedding of Nanoscale 3D SiGe islands in a Si Matrix", Physical Review Letters, Col. 81, 1998, pgs 3471-3474.
	v	
	w	
	х	

A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.